

We are so pleased to announce the recipients of AM-FPD '19 Award.

They will be presented the award in the Opening Session of AM-FPD '20 on September 1, 2020.

AM-FPD '19 Best Paper Award

SP2-2 Single-Layer Cu Gate Electrode for Large Display Devices

Hoon Kim, Bin Zhu, Rajesh Vaddi, Ming-Huang Huang, Robert Manley, *Corning Res. and Development Corp., USA*

AM-FPD '19 Poster Paper Award

P-4 Low-Temperature Process Compatibility for the Oxide Thin Film Transistors Using In-Ga-Zn-O Active Channels Prepared by Atomic-Layer Deposition at 150 °C

So-Jung Yoon¹, Seung-Bo Ko¹, Nak-Jin Seong², Kyujeong Choi², Woong-Chul Shin², Sung-Min Yoon¹, *¹Kyung Hee Univ., Korea, ²NCD Co. Ltd., Korea*

AM-FPD '19 Student Award

Sem Visal, *Tokai Univ., Japan*

P-14 Efficient Planar Perovskite Solar Cells with Entire Low-Temperature Processes via Brookite TiO₂ Nanoparticle Electron Transport Layer

AMFPD '19-ECS Japan Section Young Researcher Award

Fahmi Machda, *Kyoto Univ., Japan,*

3-3 Effects of Sputtering Gas on Crystal Growth Orientations and Durability of Al-doped ZnO Transparent Electrodes in Harsh Environment